Application No. 10/761,004 In response to Final Office Action dated February 8, 2006 Attorney Docket No. 2003-0484 / 24061.523 Customer No. 42717

## LISTING OF CLAIMS:

1. (Previously Presented) A method to singulate a circuit die from an integrated circuit wafer, said method comprising:

providing an integrated circuit wafer containing a circuit die;

cutting through said integrated circuit wafer by performing a single, continuous cut around more than one side of the perimeter of said circuit die at a time to thereby singulate said circuit die.

- (Original) The method according to Claim 1 wherein said singulated circuit die comprises a non-rectangular perimeter.
- (Original) The method according to Claim 1 wherein said singulated circuit die comprises a
  perimeter having rounded corners.
- 4. (Original) The method according to Claim 1 wherein said singulated circuit die comprises a perimeter having more than four sides.
- 5. (Original) The method according to Claim 1 wherein said singulated circuit die comprises a perimeter having three sides.
- (Original) The method according to Claim 1 wherein said singulated circuit die comprises an elliptical perimeter.
- 7. (Original) The method according to Claim 1 wherein said singulated circuit die comprises a circular perimeter.

Application No. 10/761,004 In response to Final Office Action dated February 8, 2006 Attorney Docket No. 2003-0484 / 24061.523 Customer No. 42717

- 8. (Original) The method according to Claim 1 wherein said step of cutting through is performed using a laser.
- 9. (Original) The method according to Claim 1 wherein said step of cutting through is performed using an electron beam or water jet.
- 10. (Original) The method according to Claim 1 further comprising: fixably mounting said singulated circuit die onto a package; and coupling signal pins of said package to signals in said electronic circuit.
- 11. (Previously Presented) A method to singulate a circuit die from an integrated circuit wafer, said method comprising:

providing an integrated circuit wafer by performing a single, continuous cut around more than one side of the perimeter of said circuit die at a time to thereby singulate said circuit die and wherein said singulated circuit die comprises a non-rectangular perimeter;

fixably mounting said singulated circuit die to a package; and coupling signal pins of said package to signals in said electronic circuit.

- 12. (Original) The method according to Claim 11 wherein said non-rectangular perimeter has rounded corners.
- 13. (Original) The method according to Claim 11 wherein said non-rectangular perimeter more than four sides.
- 14. (Original) The method according to Claim 11 wherein said non-rectangular perimeter has three sides.

Application No. 10/761,004 In response to Final Office Action dated February 8, 2006 Attorney Docket No. 2003-0484 / 24061.523 Customer No. 42717

- 15. (Original) The method according to Claim 11 wherein said non-rectangular perimeter is an ellipse.
- 16. (Original) The method according to Claim 11 wherein said non-rectangular perimeter is a circle.
- 17. (Original) The method according to Claim 11 wherein said step of cutting through is performed using a laser.
- 18. (Original) The method according to Claim 11 wherein said step of cutting through is performed using an electron beam or a water jet.
- 19. (Previously Presented) A method to singulate a circuit die from an integrated circuit wafer, said method comprising:

providing an integrated circuit wafer containing a circuit die;

providing a first cut partially cutting said integrated circuit wafer using a focused beam apparatus;

providing a second cut cutting through said integrated circuit wafer using a wafer saw blade apparatus;

wherein at least one of the first and second cut is performed by a single continuous cut around more than one side of the perimeter of said circuit die at a time.

20-25. (Cancelled).